

Compound Semiconductor Based Micro (Nano) Electronics

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Wrap-up of the session

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 Existing (e.g. cell phones) and emerging (e.g. Solid State Lighting) market, all provide an environment and infrastructure support that will be helopful as new III-V technologies and capabilities are explored.

Three trends:

- Scaling
- Compound SC integration in silicon technologies
- Recent III-V nanotechnologies (nanowires)

- Four decades of Compound Semicond. technol.
- Ranging from new concepts to mature, wellcharacterized, foundry technologies with important uses for society.
- Follows scaling laws, but do not challenge CMOS on the digital playground
- Facilitates key building block in systems "widening bottlenecks"
- Integrable with CMOS today in systems, longterm potential to evolve into compund-CMOS technologies.

- Bandgap engineering = a very versatile toolbox.
- Very high speed performance (f_max 1 THz)
- Very low-power performance when operated at low(er) speed.
- III-V still offers unique possibilities to integrate photonic and electronic funcdtions. Not new, but becoming more doable today!

- High-power efficiency and high-power densities for e.g. GaN Power amplifiers
- Lighting, solar cells, power electonics = much broder than "just" nanoelectronics
- Recent nano-scale III-V structures (nanowires) –
 potential for new devices and bridging the nano ← →
 micro technology integration gap (nA → mA)
- Vital field especially within MtM, expected to continue to evole and play important roles in future systems, due to advantagous properties given by nature and inventive approaches (like band-gap engineering, ...)